

**High-performance, oxidation resistance and flexible Zn@MXene/cellulose nanofibers  
electromagnetic shielding film**

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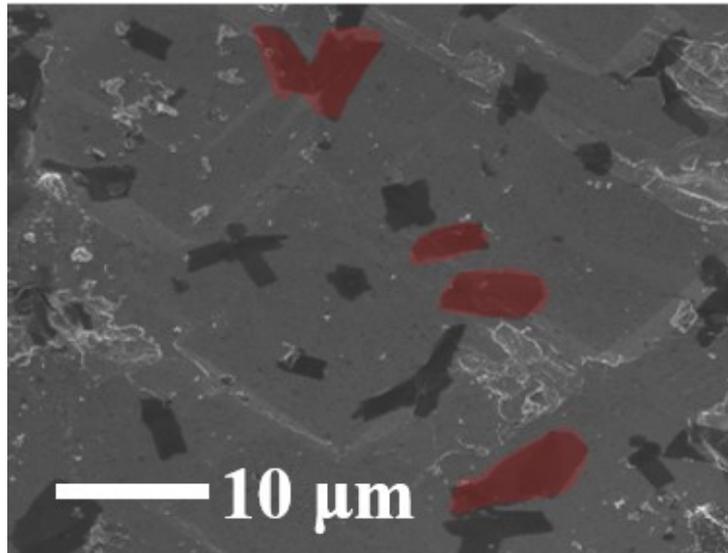
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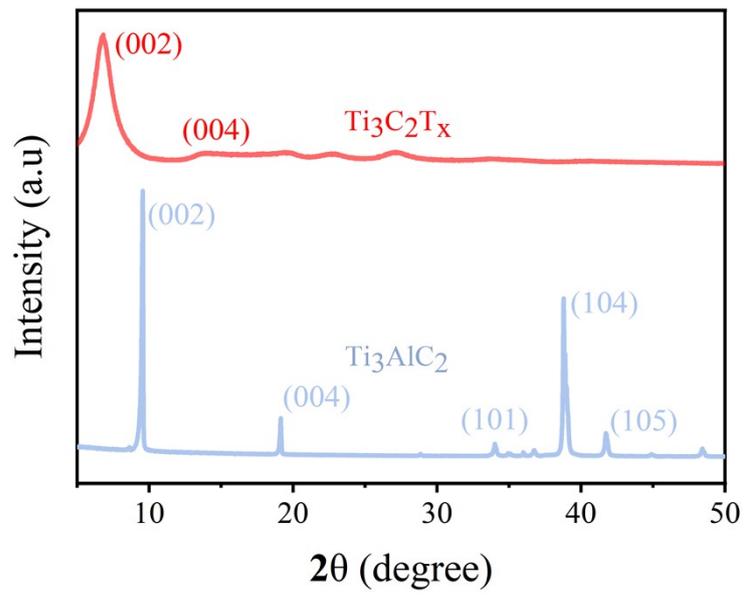
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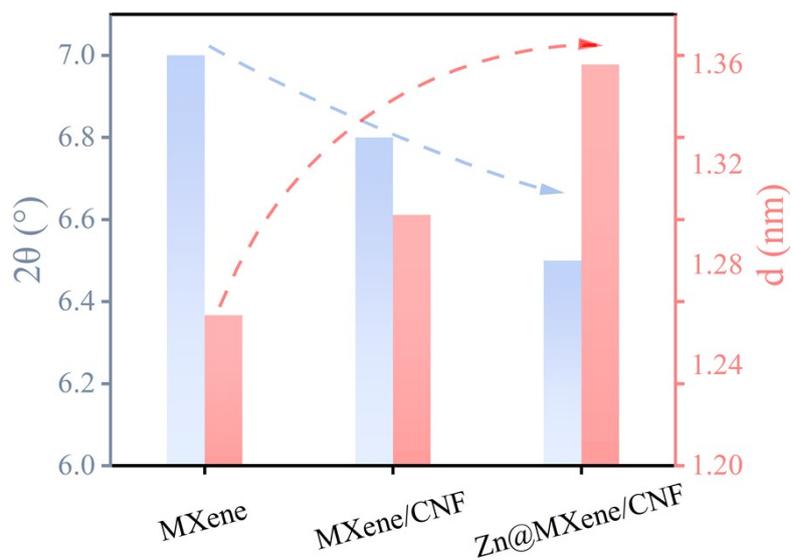
**Fig. S1. Scanning electron microscopy (SEM) image of Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>**

**MXene**



**Fig. S2. XRD spectrogram for Ti<sub>3</sub>AlC<sub>2</sub> MAX and Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>**

**MXene**



**Fig. S3. Enhancement of MXene nanosheets lamellar spacing**



**Fig. S4 Schematic diagram of self-assembly process**

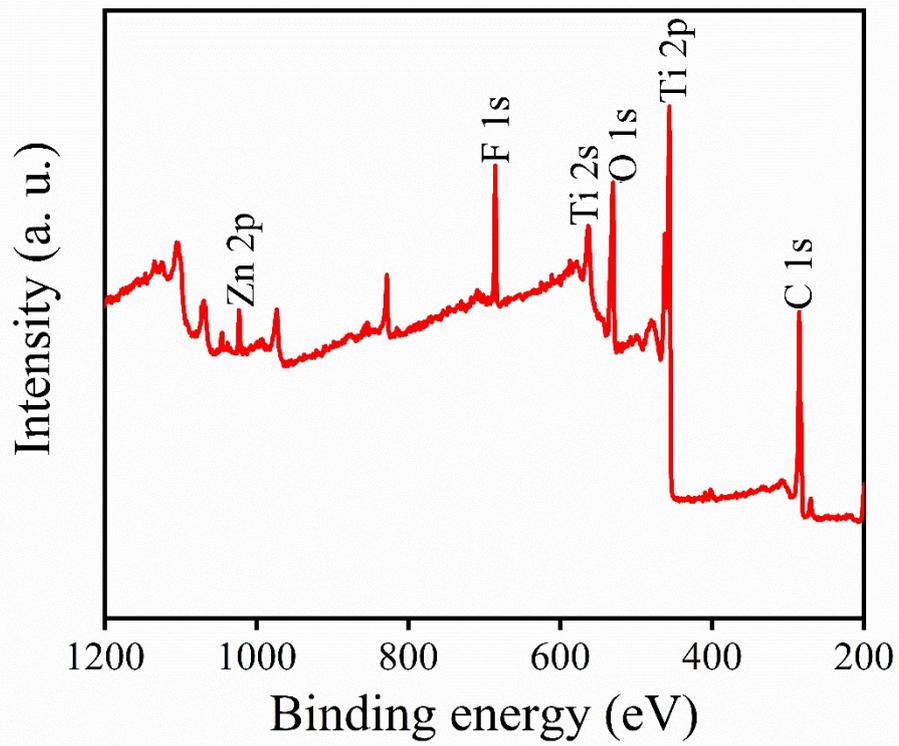


Fig. S5 XPS of Zn@MXene/CNF composite film

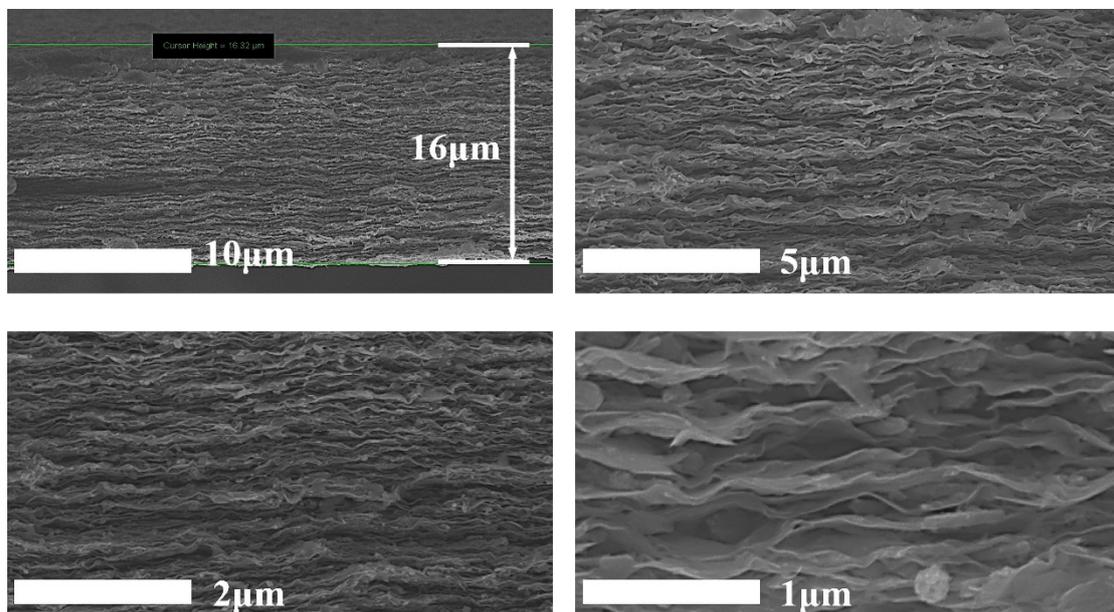
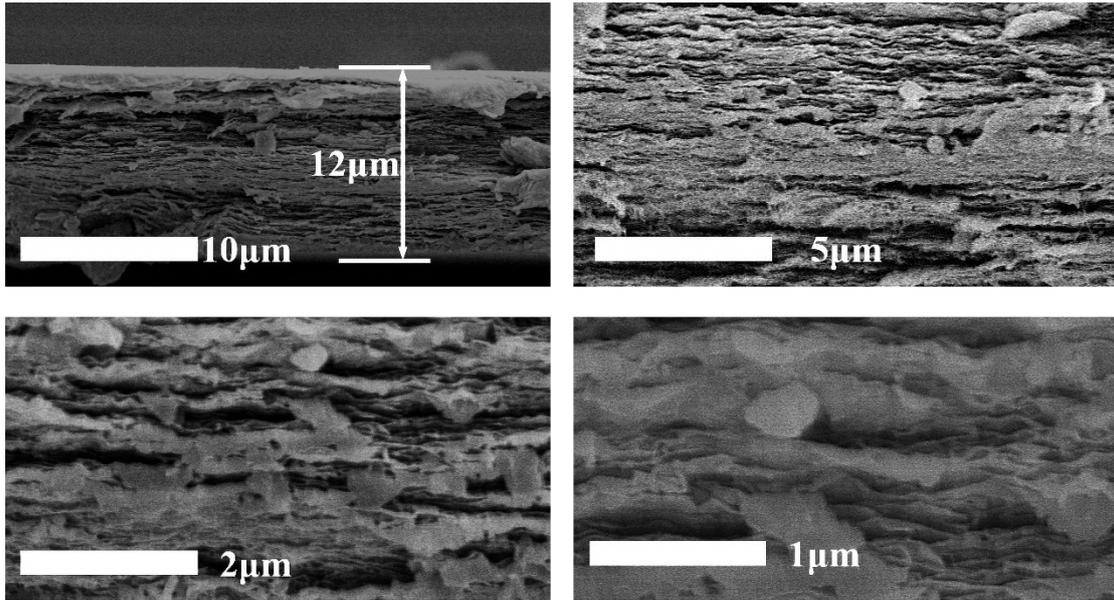
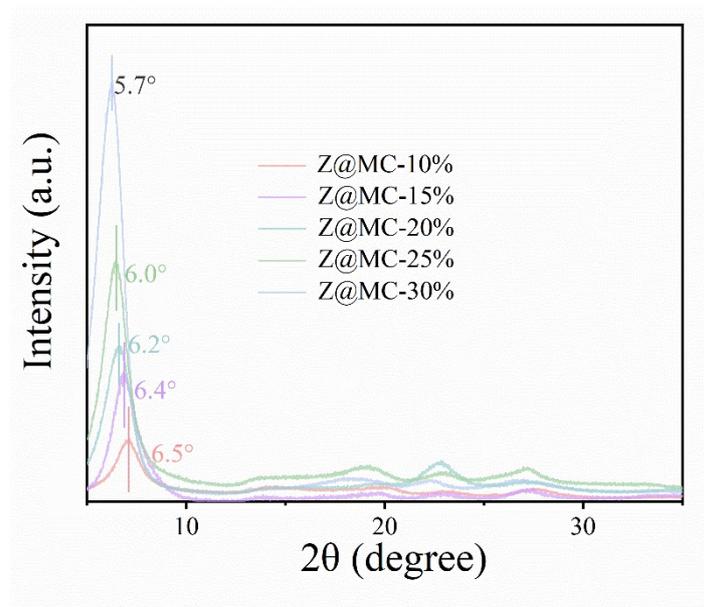


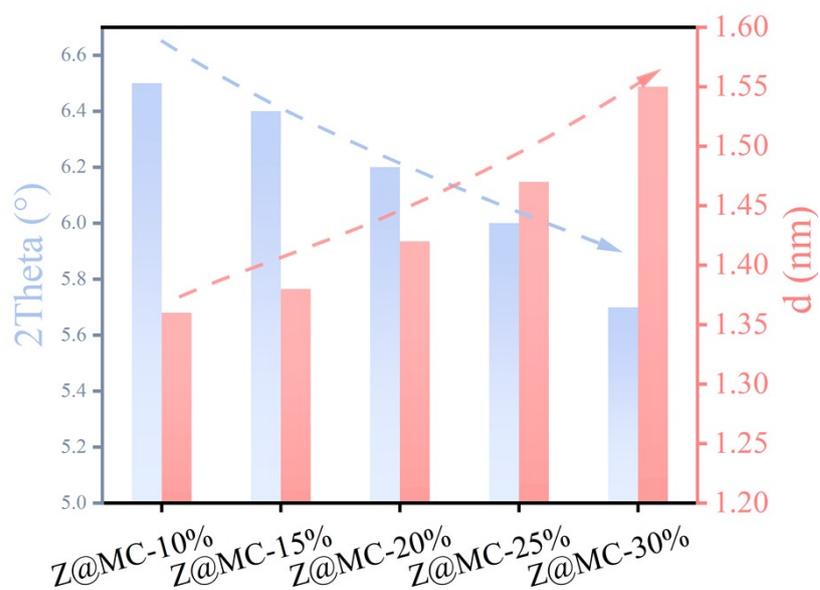
Fig. S6 SEM picture for cross section of film before hot-pressing



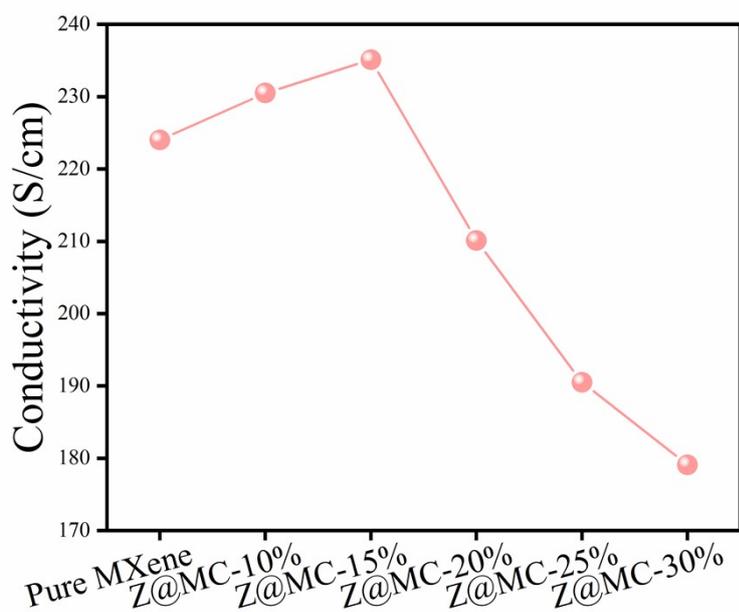
**Fig. S7 SEM picture for cross section of film after hot-pressing**



**Fig. S8 X-ray diffraction (XRD) patterns of the Zn@Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene/CNF samples**



**Fig. S9 Enhancement of MXene nanosheets lamellar spacing**



**Fig. S10 Electrical conductivity of film samples**